

Crystal structure and magnetic properties of Fe_xPd_{1-x} thin films annealed at 550 °C

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Abstract Polycrystalline Fe_xPd_{1-x} (x = 37–64 at.%) films with thicknesses of 47 ± 2 nm were prepared by dc magnetron sputtering on quartz glass substrates and subsequent annealing at 550 °C for 3 h. The evolution of crystal structure and magnetic properties with different Fe concentrations were investigated. For the Pd-rich FePd films, the A1 disordered phase and soft magnetic properties were found. The Fe-rich FePd films are more favorable to the formation of an ordered L10 phase. For Fe concentration of 51 at.%, the sample exhibits the highest coercivity, magnetic energy product and remanence ratio at room temperature, corresponding to 3.5 kOe, 17.6 MGOe and 0.94, respectively, and the coercivity increases to \sim 4.3 kOe at 120 K. The disorder-order transition temperature is evidently reduced to 550 °C and magnetic properties are improved in this work. These FePd films have shown promise for application as high-density magnetic recording medium.

1 Introduction

 $L1_0$ ferromagnetic alloys, such as FePt, CoPt, and FePd, have been extensively investigated for the potential applications in the recording media, spintronic devices,

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² Guangxi Key Laboratory of Information Materials, Guilin University of Electronic Technology, Guilin 541004, China microelectromechanical systems, owing to their excellent corrosion resistance and magnetically intrinsic properties, including strong uniaxial magnetocrystalline anisotropy ($K_u = 1-7 \times 10^7 \text{ erg/cm}^3$), large saturation magnetization ($4\pi M_s = 12-14 \text{ kG}$), and high Curie temperature ($T_c \sim 450-550 \text{ °C}$) [1–5]. For recording media applications, FePt was considered as the most promising candidate [6–8]. Nevertheless, the high coercivity in the range of 10–20 kOe of L1₀ FePt with nanogranular microstructure results in difficulty in magnetic writing. To solve this, heat assisted mechanism must be involved, which increases the complexity of the system. L1₀-FePd, having a much lower magnetic anisotropy field (H_k) of 37 kOe as compared to L1₀ FePt (120 kOe) but a comparable K_u, is therefore received considerable attention in recent years [9–12].

FePd thin films exhibit a disordered face centered cubic (fcc) structure at room temperature, which behave magnetically soft. In general, after annealed at 600-700 °C, the structure of samples could transform to an ordered face centered tetragonal (fct) structure [13]. Epitaxial $L1_0$ -FePd films grown on MgO(001) single crystal substrates were reported to display a H_c below 1 kOe [14, 15]. Magntic energy product ((BH)_{max}) of 8.1 MGOe with $H_c = 3.0$ kOe was obtained for L1₀-FePd nanoparticles with size in the range of 30-50 nm [16]. However, high cost of MgO (001) single crystal substrate and the inaccessible control on size distribution and compacted assembly make them not favorable for practical applications. Recently, Chang et al. [17] reported that sputter-prepared FePd films on glass substrates with W underlayer behaved well in magnetic properties after annealed at 650 °C, which manifested H_c and $(BH)_{max}$ about 3.0 kOe and 8.7 MGOe, respectively. For practical application, however, the temperature is still too high for realization of the disorder-order phase transformation of the FePd films.

In our previous work, we added successfully Si–N amorphous content to FePd films, and obtained a good magnetic property [18]. In this paper, pure Fe_xPd_{1-x} films with Fe concentration of 37–64 at.% were deposited on cheap quartz glass substrates, without any buffer layer and doped element. Interestingly, the films displayed also high degree of ordering and high coercivity at 550 °C, indicating a lower ordering transition temperature.

2 Experimental details

 Fe_xPd_{1-x} (x = 37-64 at.%) thin films with thicknesses of 47 ± 2.0 nm were prepared on quartz glass substrates at room temperature, using dc magnetron sputtering. The pure Pd disk with Fe sectors was used as the sputter target and the purity of the Fe and Pd was better than 99.99%. The sputtering chamber was evacuated to a base pressure of 6.0×10^{-5} Pa. High-purity argon (99.99% purity) was used as the working gas. During sputtering, the ambient gas pressure, the gas flow rate and the dc power were maintained at 1.5 Pa, 24 SCCM (cubic centimeter per minute at STP) and 100 W, respectively. The distance between the cathodes and the substrate was set at 70 mm. After deposition, films were annealed at 550 °C under high vacuum $(6.0 \times 10^{-2} \text{ Pa})$ for 3 h. The crystal structure and magnetic properties of the films were investigated by X-ray diffraction (XRD, PANalytical Empyrean, U = 45 kV/I =40 mA, X'celerator, Cu-K α_1 : $\lambda = 1.54056$ Å, 0.0167[°]/ step), physical properties measurement system (PPMS-9T, Quantum Design Co.), atomic force microscopy (AFM, BRUKER DIInnova) and scanning electron microscopy (SEM, FEI Quanta 450 FEG). The maximum magnetic field used was ± 3 T. The atomic concentration for each element in the films was determined by energy dispersive X-ray spectrometer (EDS, Oxford instruments X-Max20).

3 Results and discussion

Figure 1a illustrates XRD patterns of the polycrystalline Fe_xPd_{1-x} films annealed at 550 °C with various Fe concentrations from 37 to 64 at.%. For the films with Fe \leq 37 at.%, no superlattice peaks of the fct phase except the disorder-fcc fundamental peaks are observed, indicating that the films are solid solution with single disordered fcc structure. For the film with Fe = 43 at.%, the splitting of the (200) reflection of the fcc structure to the (200) peak and the weak (002) superlattice peak of the fct structure resulting from the break of lattice symmetry is observed, which indicates the film has begun to transform from fcc to fct structure. But at this time it is still dominated by the disordered fcc phase, indicating that Pd-rich FePd films have a poor degree of order. With increasing the Fe content further to 51 and 64 at.%, respectively, the (002) superlattice peak becomes well defined, a large number of $L1_0$ ordered fct structures were formed, indicating that the Ferich FePd films are more favorable to the formation of an ordered $L1_0$ phase. In addition, the (111) diffraction peak shifts to high angle as the Fe concentration increases as shown in Fig. 1b. This is because that the atomic radius of Fe is smaller than that of Pd, resulting in the shrinking of the lattice plane after more Fe atoms substituting for the Pd atoms.

The in-plane hysteresis loops of the Fe_xPd_{1-x} films with different chemical composition are illustrated in Fig. 2a. For the film with Fe content of 37 at.%, the loop reaches the saturation easily with a low H_c of ~0.1 kOe, showing a

Fig. 1 XRD patterns of Fe_xPd_{1-x} (x = 37–64 at. %) thin films (**a**) and the enlarged patterns of (111) diffraction peaks (**b**)







typical magnetically soft behavior, due to the presence of the disordered FePd phase that exhibits low K_u . With increasing Fe content to 43 at.%, the H_c increases rapidly to 1.2 kOe, indicating the occurrence of L1₀ ordering at 550 °C. The H_c reaches a maximum value of 3.5 kOe at the nearly equiatomic composition, and at the same time the loop of Fe₅₁Pd₄₉ film also shows a good squareness, which indicates the degree of ordering of the sample has been very high, up to 0.95. In Ref. [19], the H_c of FePd films deposited on glass substrate is ~3.4 kOe after being annealed at 700 °C. In contrast, the temperature of fcc–fct phase transition is set to 550 °C in present work, which is the 150 °C lower than that in Ref. [19], whereas the coercivity is improved to 3.5 kOe. With higher Fe content up to 64 at.%, the H_c decreased to 2.3 kOe. In addition, the saturation magnetization (M_s) varies nonlinearly with increasing Fe content, suggesting that the maximum magnetization does not simply rely on the concentration of magnetic atoms based on the assumption that the magnetic moment of Fe remains constant while Pd does not

Fig. 3 AFM and SEM images of $Fe_{51}Pd_{49}$ films as-deposited (a, b) and annealed at 550 °C (c, d)





Fig. 4 In-plane hysteresis loops at 300 and 120 K for $Fe_{51}Pd_{49}$ films annealed at 550 °C, respectively

contribute any magnetic moment. Nevertheless, the magnetic moment of Fe was found to depend on the chemical composition of FePd alloys based on in situ neutron diffraction experiments [20]. Besides, the magnetic structure may also be altered by the crystal structure of FePd alloys, i.e., as the crystal structure changes between A1 and $L1_0$ in FePd alloys, its magnetic structure will also be altered.

Figure 2b shows remanence ratio (M_r/M_s) and $(BH)_{max}$ versus Fe content. The Fe content dependence of M_r/M_s and (BH)_{max} show a strong consistent trend with that of the H_c . For the films with Fe content of 37 at.%, the M_r/M_s is only 0.44 and (BH)_{max} is almost zero due to low coercivity. As the Fe content is increased to 43 at.%, the sample undergoes the fcc-fct transition, Mr/Ms increases rapidly to 0.75, and (BH)_{max} to 6.8 MGOe. At the nearly equiatomic composition, the degree of the ordering in the film is so high that Mr/Ms is close to 1 and Hc also reaches a maximum value of 3.5 kOe, which leads (BH)max to 17.6 MGOe. The H_c, M_r/M_s and (BH)_{max} obtained in our work are also better than those of the FePd films with W as underlying [17], which makes the preparation process simplified. As the Fe content is increased further to 64 at.%, the M_r/M_s and $(BH)_{max}$ decrease slightly to 0.89 and 14.8 MGOe, respectively, which indicates the Fe-rich FePd films were more favorable for the formation of the ordered $L1_0$ phase. The results were consistent with the results of XRD analysis.

AFM and SEM images of the Fe₅₁Pd₄₉ films as-deposited (a, b) and annealed (c, d) at 550 °C are shown in Fig. 3. For the as-deposited films, it shows that the surface of the film is flat, loose, and homogeneous. A smooth surface with surface roughness $R_a = 0.377$ nm was demonstrated. After annealing at 550 °C, the sample surface morphology becomes compact, agglomerate and island-like state, surface R_a increases to 2.70 nm. Besides, holes were clearly observed, as shown in Fig. 3d. Because

there are large differences in the thermal expansion coefficient between FePd layer and quartz glass substrate, holes form in the films after post-annealing at 550 °C due to stress release and the characteristic of thin film, which gives rise to magnetoelastic effects. The result is consistent with the conclusion of Carbucicchio et al. [21]. It suggests that the interface effects may play an important role on $L1_0$ ordering of FePd films.

Figure 4 exhibits the in-plane hysteresis loops at 300 and 120 K for $Fe_{51}Pd_{49}$ films annealing at 550 °C, respectively. By contrast, loop of 120 K shows a higher H_c and (BH)_{max}, about 4.3 kOe and 24.2 MGOe respectively. The magnetic properties are composition dependent and are affected by Fe–Pd interactions within the particles [22]. The relatively large H_c of $Fe_{51}Pd_{49}$ may results from the large anisotropic field and optimized microstructure. These FePd films show a promise for application as high-density magnetic recording medium.

4 Conclusions

 Fe_xPd_{1-x} (x = 37-64 at.%) films of 47 nm in thickness with different Fe concentrations were prepared on quartz glass substrates by dc magnetron sputtering. The crystal structure and magnetic properties of the films were characterized. The results show that the Fe_xPd_{1-x} films with Fe concentration $x \leq 37$ at.% has disordered structure and soft magnetic properties. For the Fe₄₃Pd₅₇ films, the fcc-fct phase transition begins to occur in the sample after a heat treatment at ~550 °C. When the Fe content is close to equiatomic composition, the performance of the $Fe_{51}Pd_{49}$ film is optimal, the H_c , M_r/M_s and $(BH)_{max}$ reach to 3.5 kOe, 0.94 and 17.6 MGOe at 300 K, respectively, and the H_c increases to ~4.3 kOe at 120 K. In this work the preparation process of FePd films is simplified, the temperature of fcc-fct phase transition is lowered to 550 °C and better magnetic properties are achieved. The correlation between the structure and magnetic properties provides basic insights and useful information for further development of FePd-based application.

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